

| Ref # | Hits | Search Query | DBs | Default Operator | Plurals | Time Stamp |
|-------|--------|---|---|------------------|---------|------------------|
| L1 | 46054 | psm or (((phase adj shift) or (phase-shift)) adj mask) or photomask or (photo-mask) or (photo adj mask) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2004/11/29 09:47 |
| L2 | 593893 | offset | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2004/11/29 09:47 |
| L3 | 21804 | (target or wafer or cathode or substrate) with 2 | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2004/11/29 09:47 |
| L4 | 115 | 1 same 3 | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2004/11/29 09:50 |
| L5 | 194729 | sputter\$3 | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2004/11/29 09:50 |
| L6 | 93 | (1 same 5) and 3 | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2004/11/29 09:50 |